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**PATENT NUMBER and  
ISSUE DATE**

**U.S. UTILITY Patent Application**

APPL. NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10082658	10/19/2001	378	119	2882	Thomas, C

**APPLICANTS:** Richardson Martin;

**\*\*CONTINUING DATA VERIFIED:**

THIS APPLICATION IS A CIP OF 09/881,620 06/14/2001

AND CLAIMS BENEFIT OF 60/242,102 10/20/2000

verified *CT*

**\*\* FOREIGN APPLICATIONS VERIFIED:**

none *CT*

PG-PUB DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☐ yes ☒ no

35 USC 119 conditions met ☐ yes ☒ no

Verified and Acknowledged Examiners's initials

ATTORNEY DOCKET NO

UCF-306CIP

**TITLE :** EUV, XUV, and X-ray wavelength sources created from laser plasma produced from liquid metal solutions, and nano-size particles in solutions

U.S. DEPT. OF COMM. / PAT. & TM. PTO-436L (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS</b>	
7/02/03		Total Claims	Print Claims for
		28	03 1
<b>ISSUE FEE</b>		<b>DRAWING</b>	
Amount Due	Date Paid	Sheets Drawn	Fig. Drawn
\$950		6	8
<input type="checkbox"/> <b>TERMINAL</b>		Print Fee	2.4
<b>DISCLAIMER</b>		Application Examiner 7/2/03	
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